



SEPTEMBER 19-22, 2017 - SINGAPORE

RECENT PROGRESS IN GRAPHENE
& 2D MATERIALS RESEARCH



Hetero-integration of Graphene and hBN towards Nano-electronics

Haomin WANG (王浩敏)

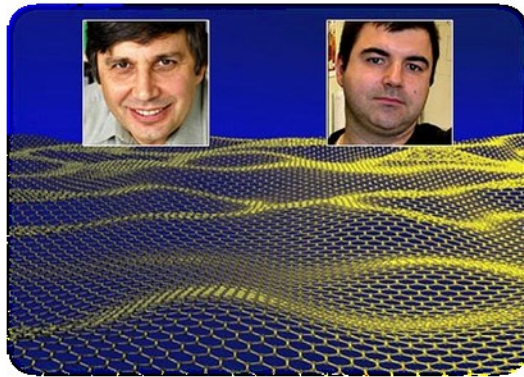
*State Key Laboratory of Functional Materials for Informatics,
Shanghai Institute of Microsystem and Information Technology,
Chinese Academy of Sciences*

2017/9/19

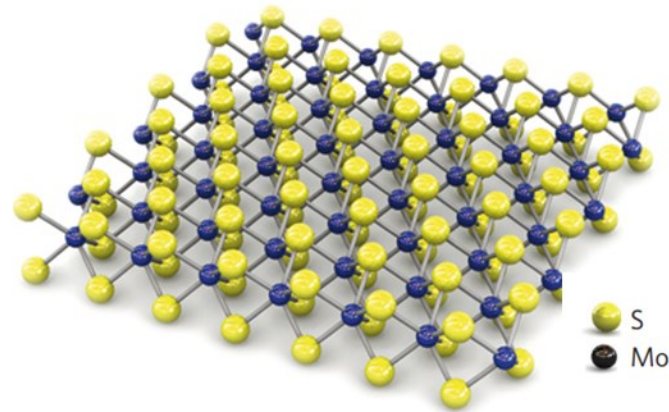
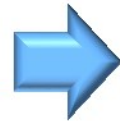
Outline

- **Background**
- **Our Approach**
- **Growth Mechanism**
- **GNRs Preparation**
- **Summary**

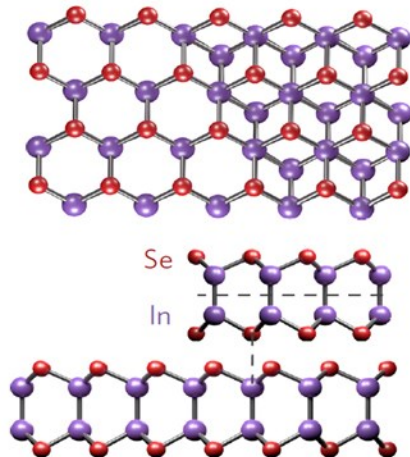
Family of 2D Materials



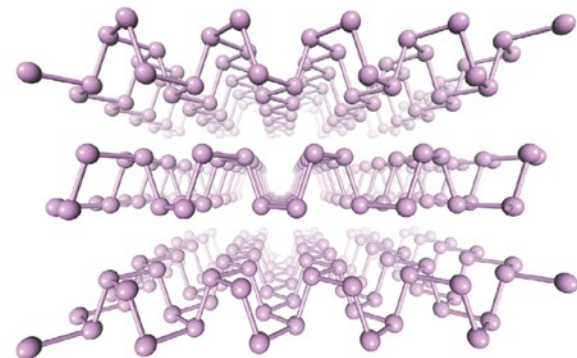
2004 Graphene
2010 Nobel Prize



2010 MoS₂

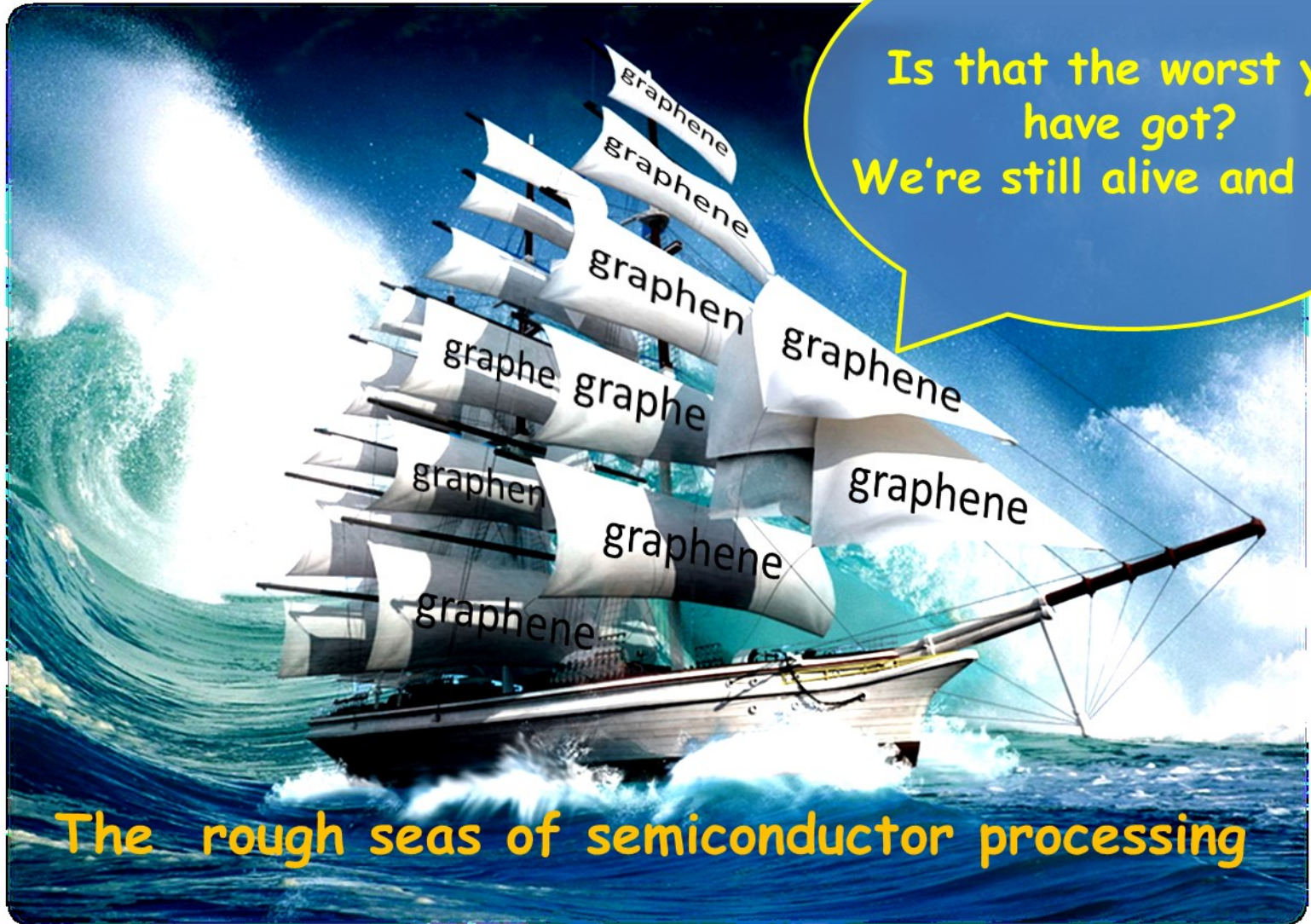


2016 InSe



2014 black Phosphene

Why still graphene?

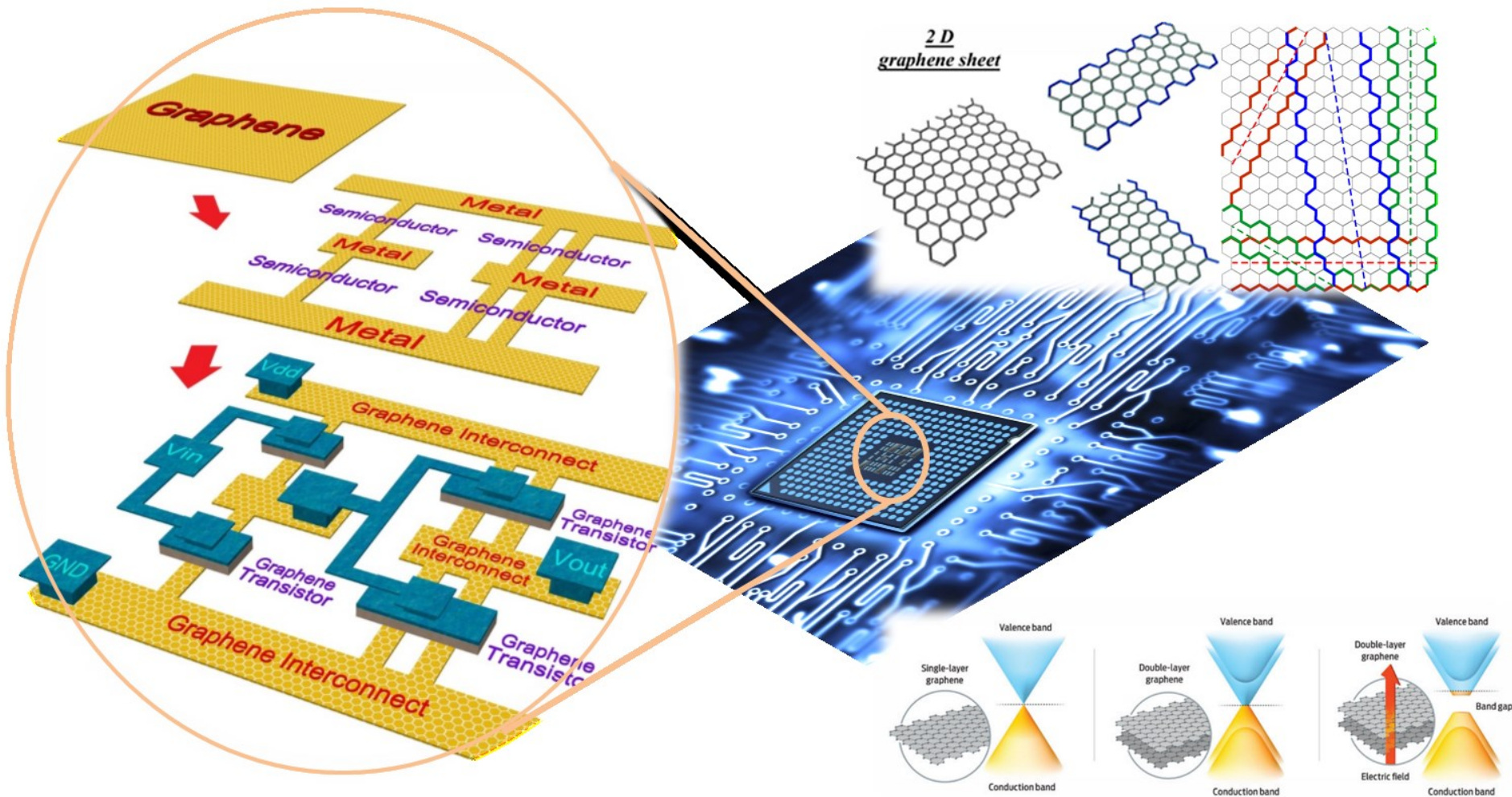


Is that the worst you have got?
We're still alive and well!

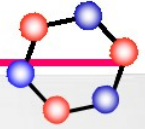
The rough seas of semiconductor processing

Research Focus

Development of graphene materials for micro/nanoelectronics



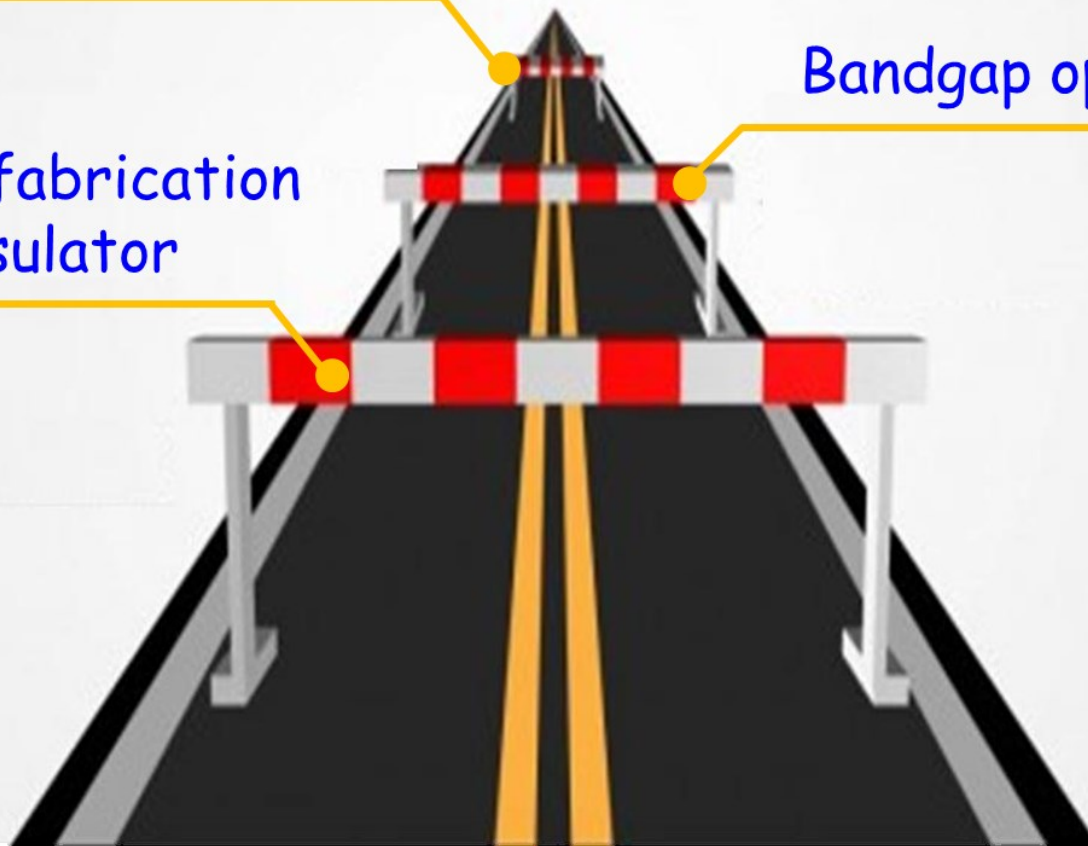
Challenges in Materials Preparation



Compatible with processes of semiconductor industry

Scalable fabrication on insulator

Bandgap opening

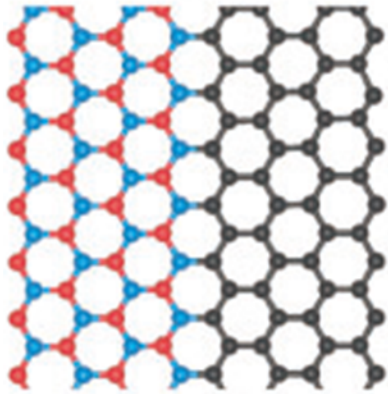


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Hetero-integration of graphene and *h*-BN

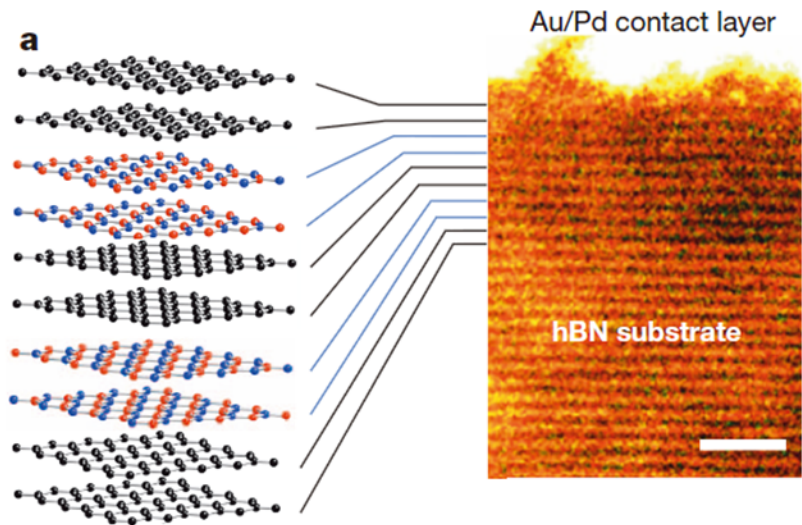
In-plane



h-BN Graphene

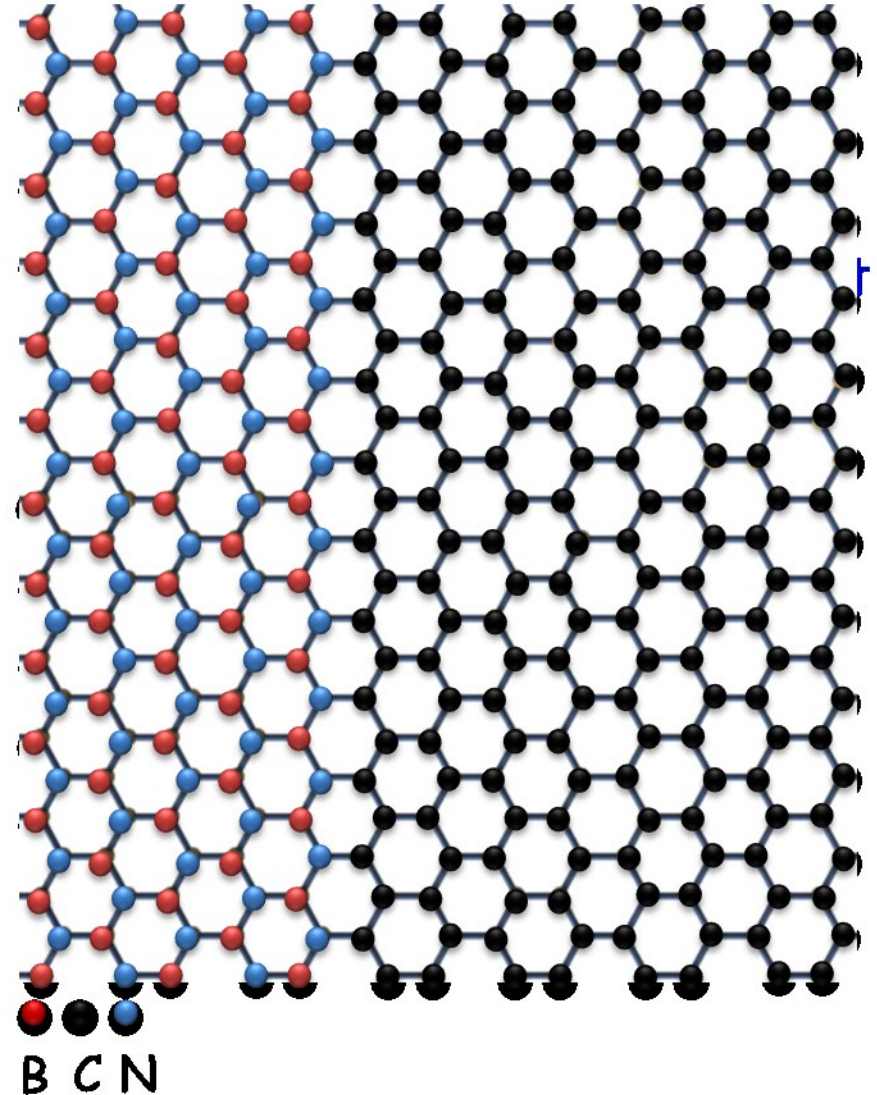
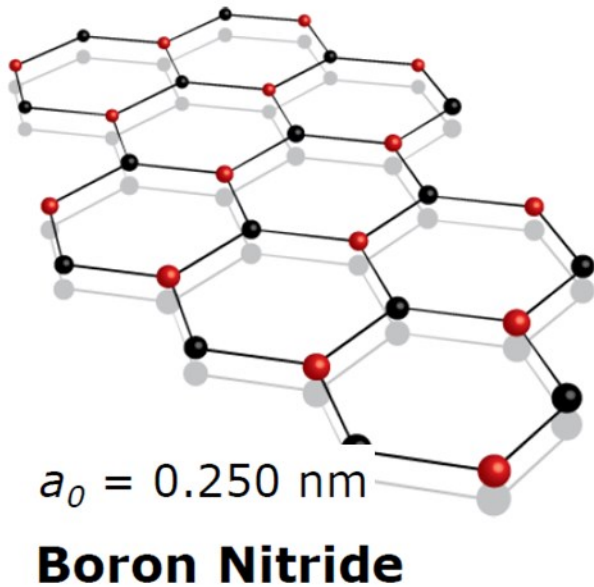
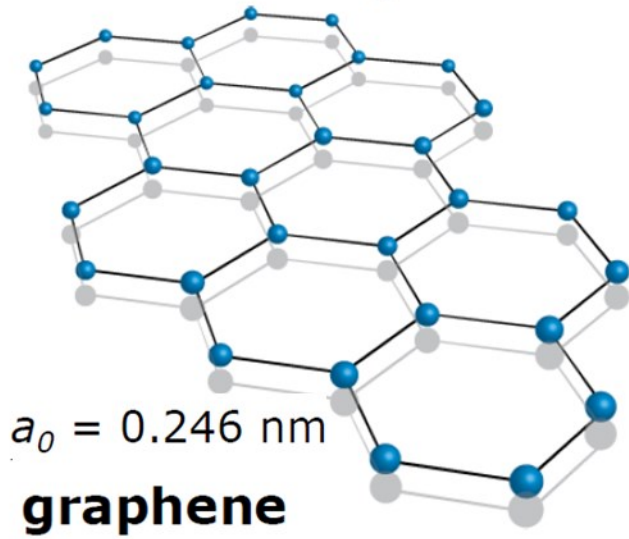


van der Waals

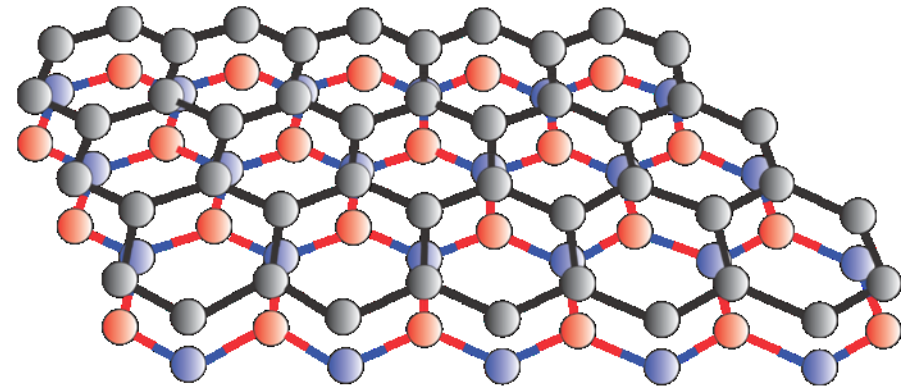
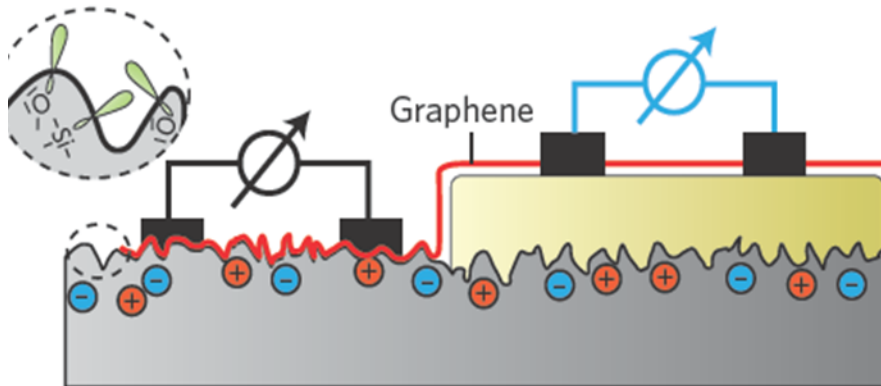
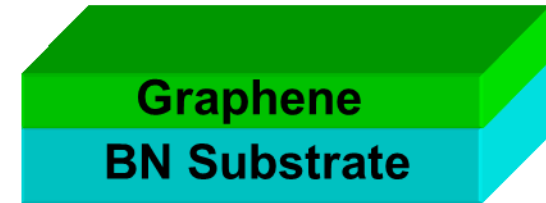
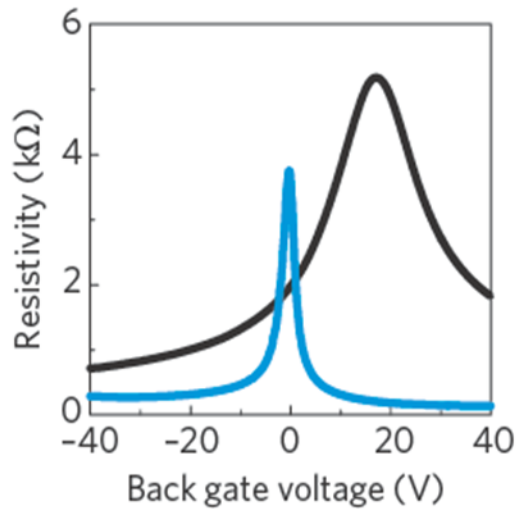


Adapted from Geim *et al.* Nature (2013),
Ajayan, *et al.* Nature Materials (2014)

In-plane Heterostructure



van der Waals Heterostructure

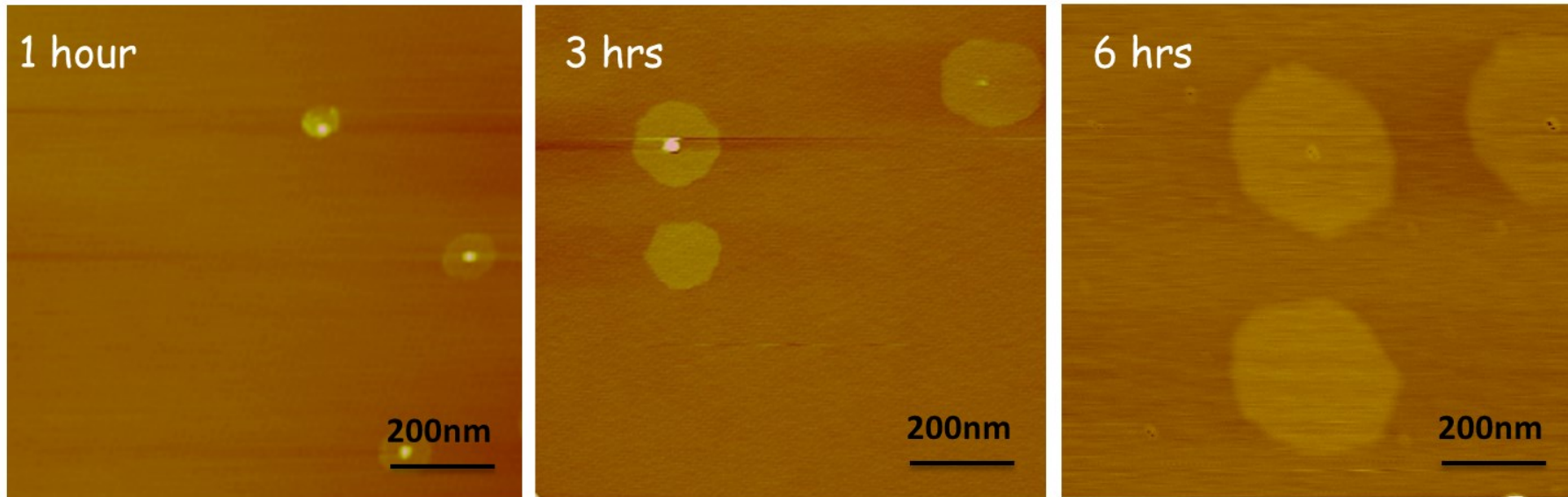


Credit :R. Thomas Weitz and Amir Yacoby
Dean, C. R. *et al.* Nature Nanotech. 5, 722–726 (2010).

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Nucleation at Imperfections

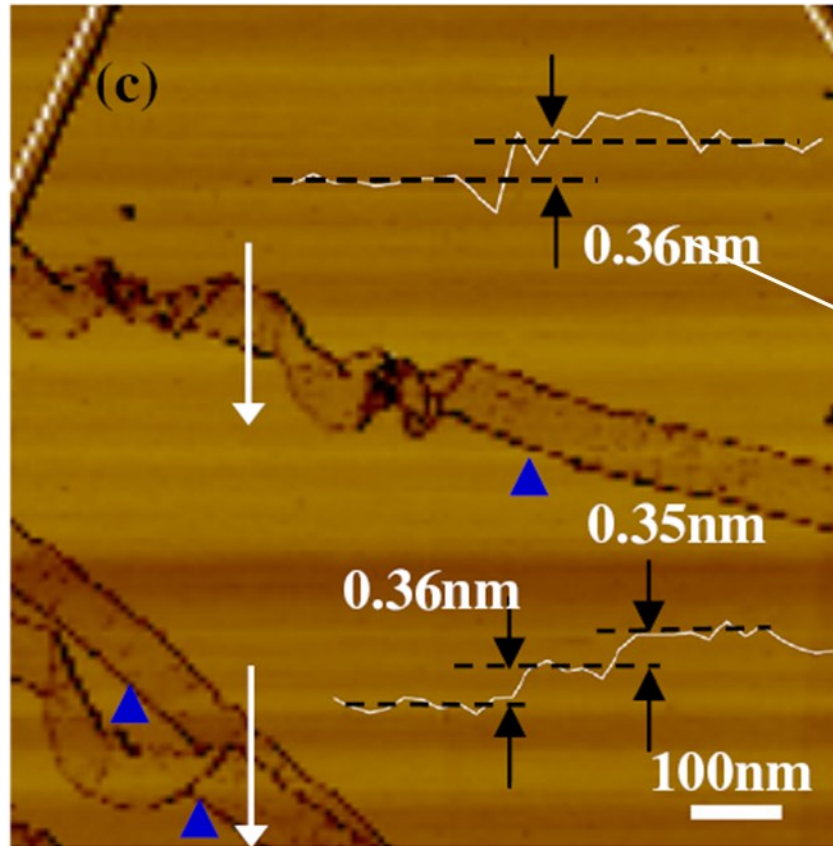


1200° C; CH₄/H₂ = 5 : 5sccm; Growth rate = 1~2nm/mins

- Domains nucleate at defective sites
- Domain size grow with increasing of deposition time

Tang S., et al. Carbon, 50, 329-331 (2012)

Nucleation at Imperfections

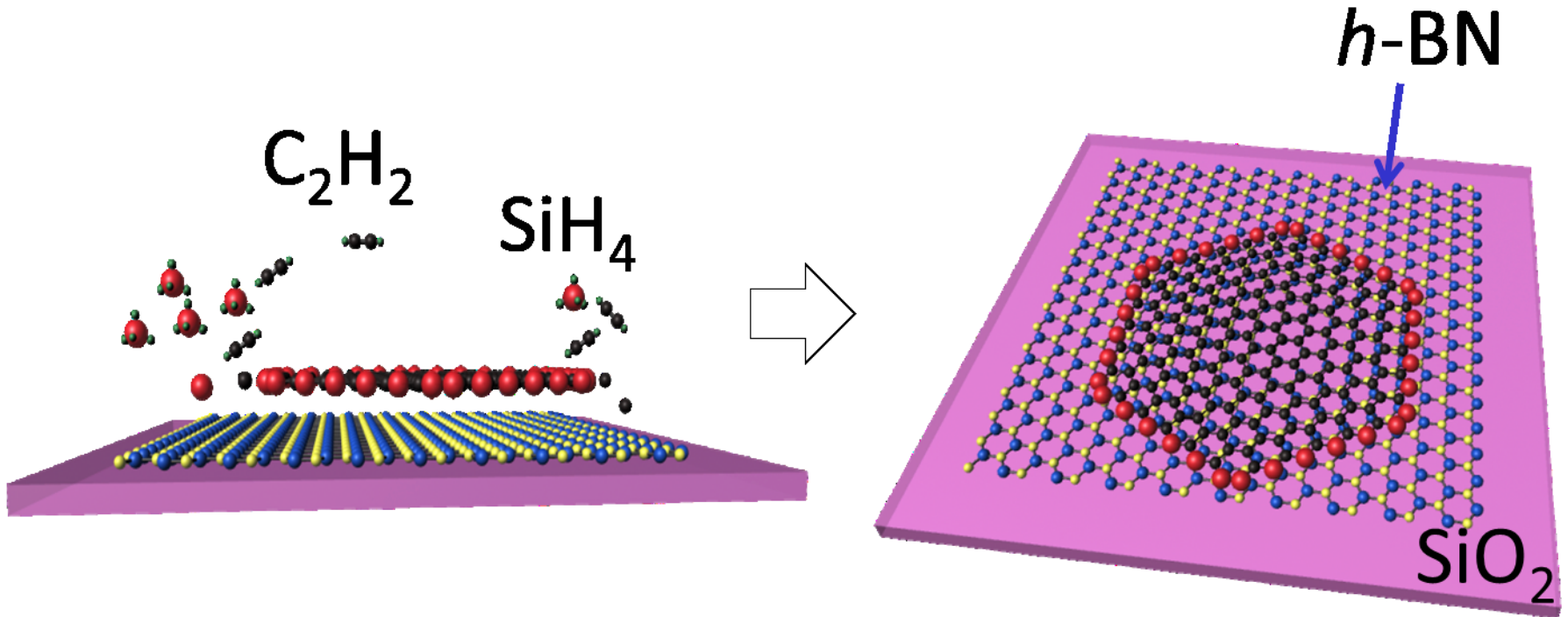


Most likely by step-flow mechanism

Tang S. *et al.* Carbon, 50, 329-331 (2012)

Strategy for Graphene Growth on *h*-BN

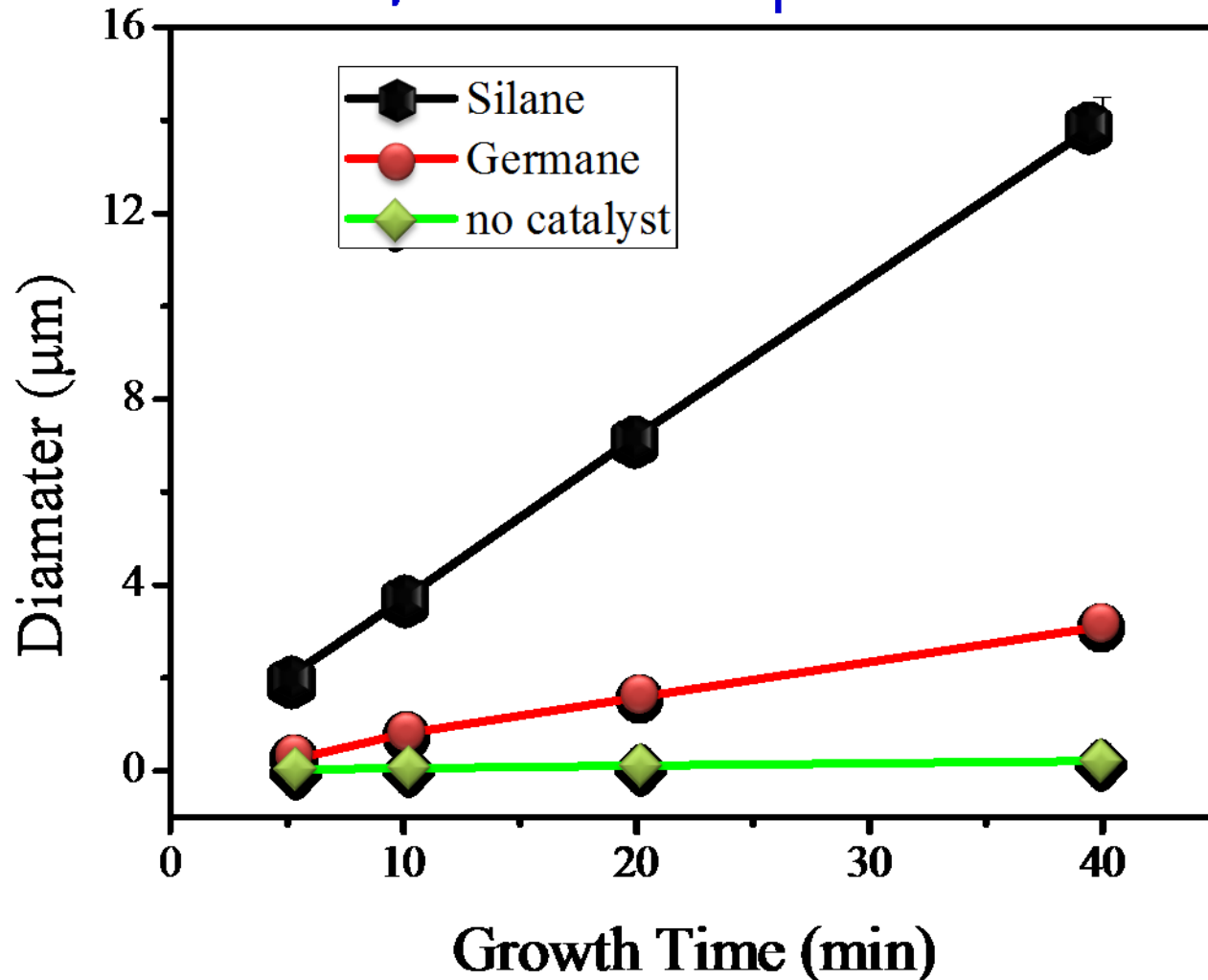
◆ Gaseous catalyst assisted growth



Growth rate increases from 1~2nm/min to 1 μ m/min
Diameter of crystal grain from 300nm to 20 μ m

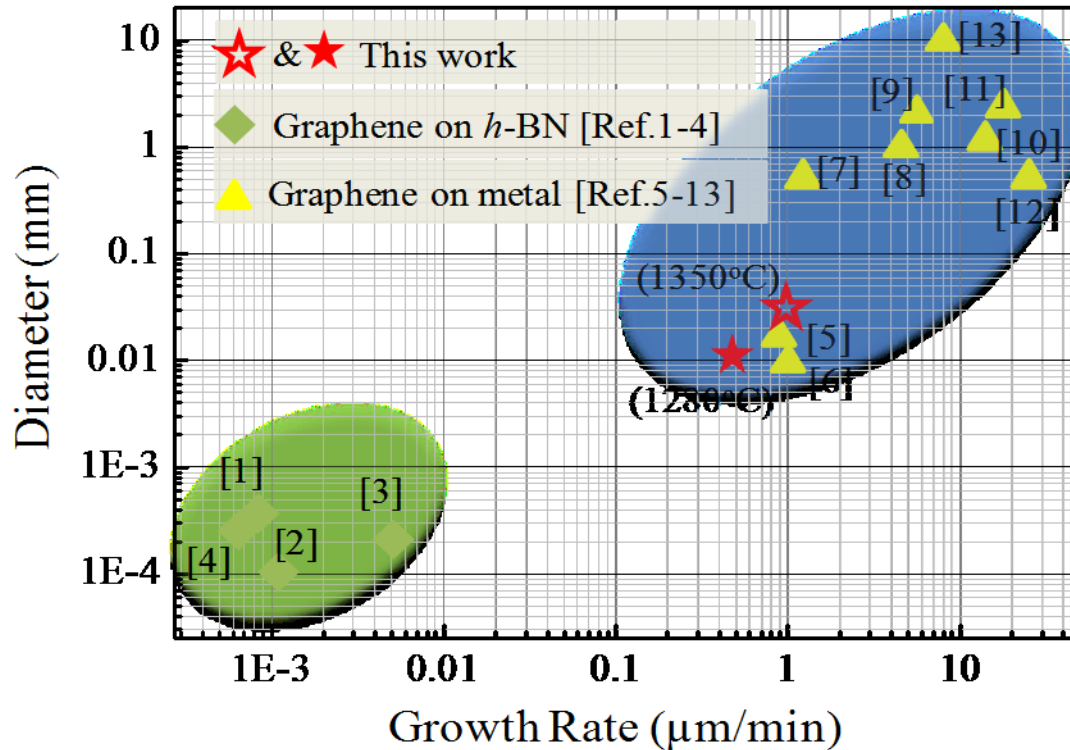
To Increase Growth Rate

Metal, Si and Ge vapors work well.



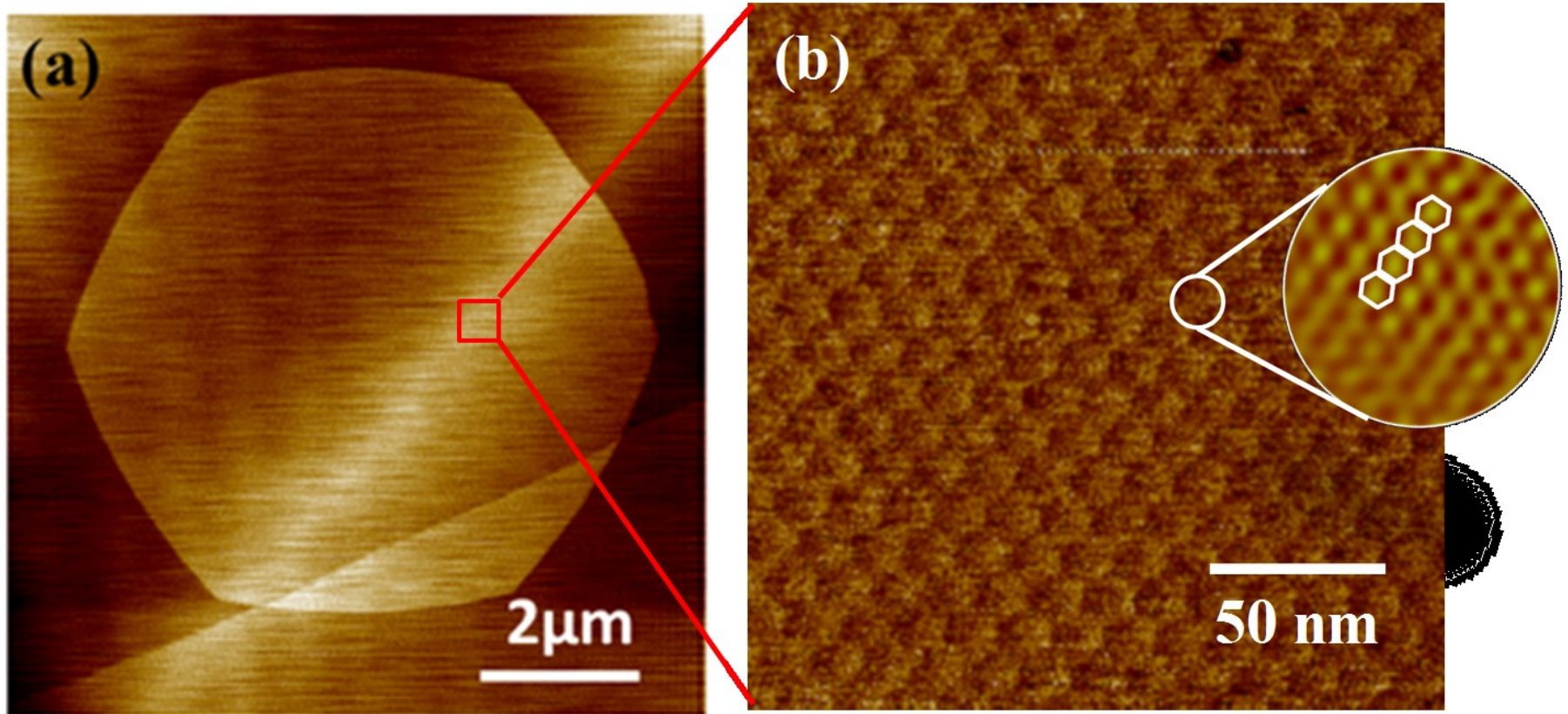
Tang S. Wang H. *et al.* Nature Commun., 6, 6160 (2015)

Growth Rate and the Domain Size



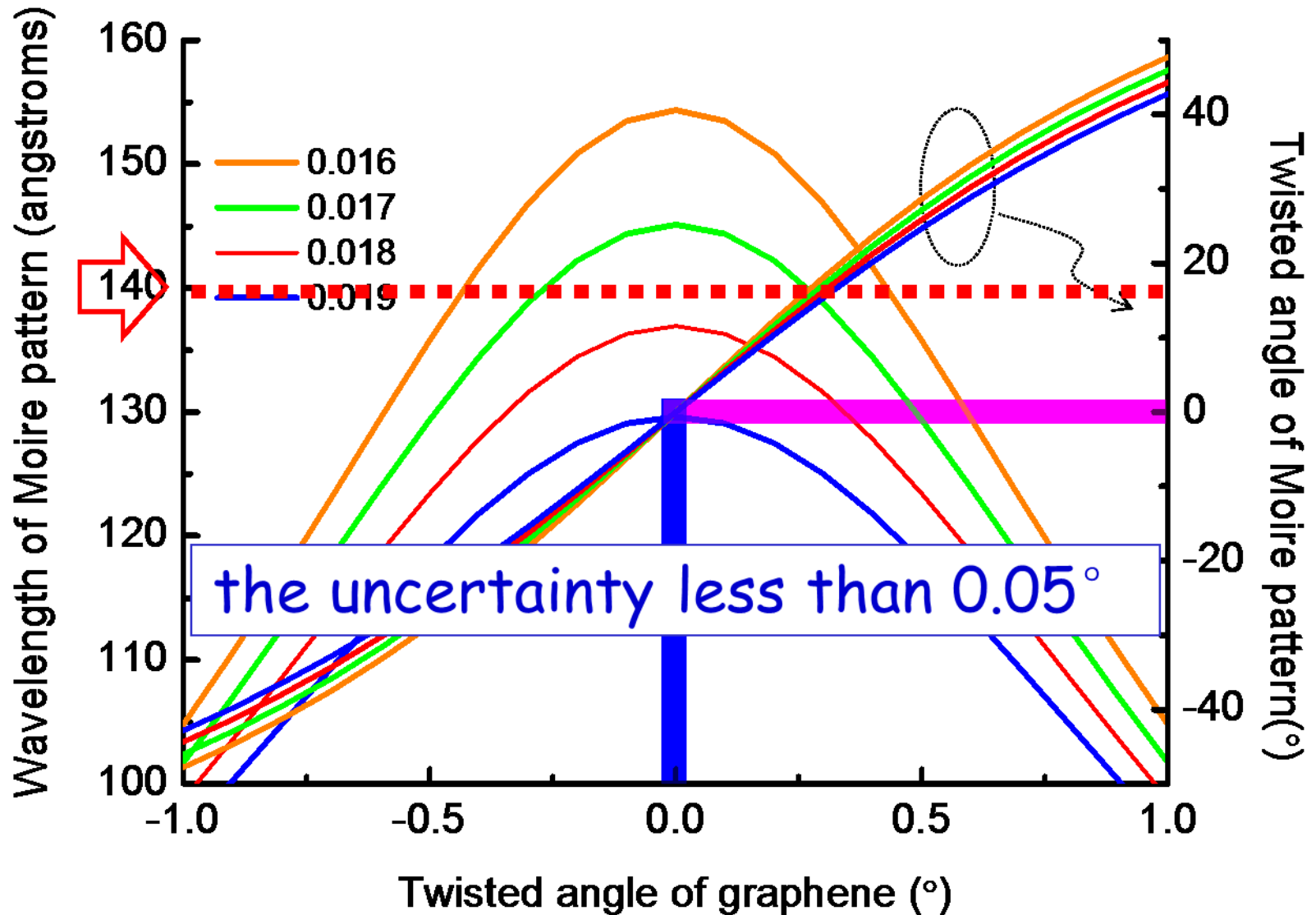
- ✓ Growth rate up to 1 $\mu\text{m}/\text{min}$
- ✓ single crystal up to 20 μm
- ✓ Comparable with CVD graphene on Cu in the early days

Precisely Aligned Graphene Domains



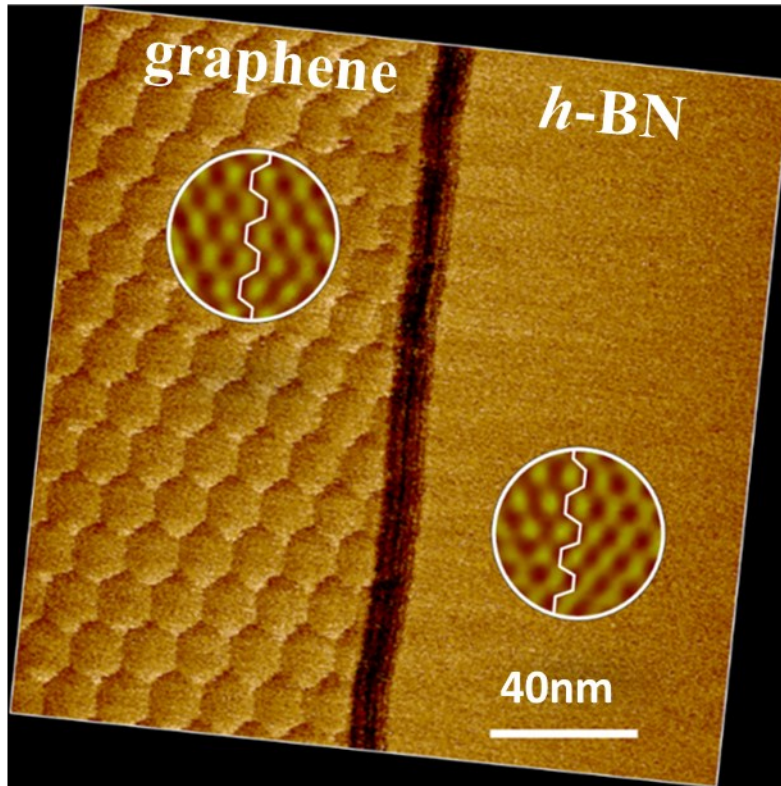
Moiré pattern gives the information of
graphene alignment on *h*-BN

High Sensitivity of Moiré Patterns

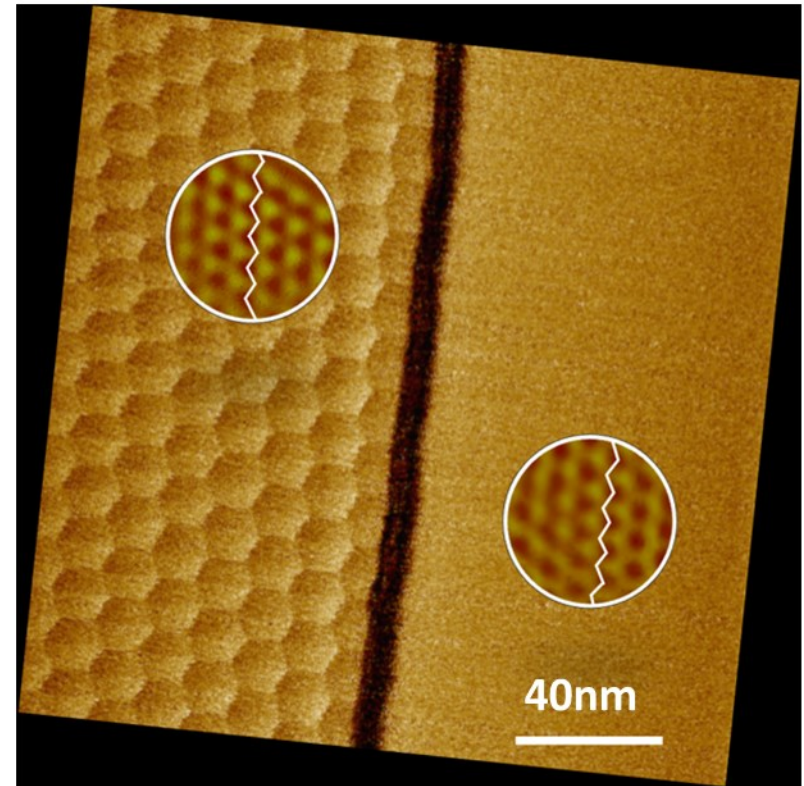


Tang S., Scientific Reports 3:2666 (2013)

Edge Control of Graphene Domains

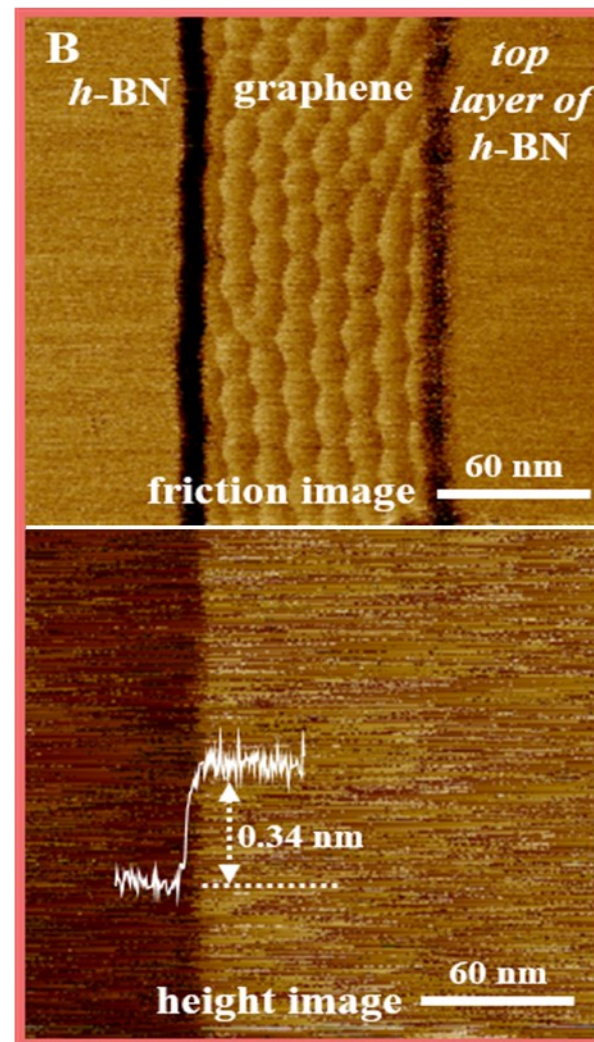
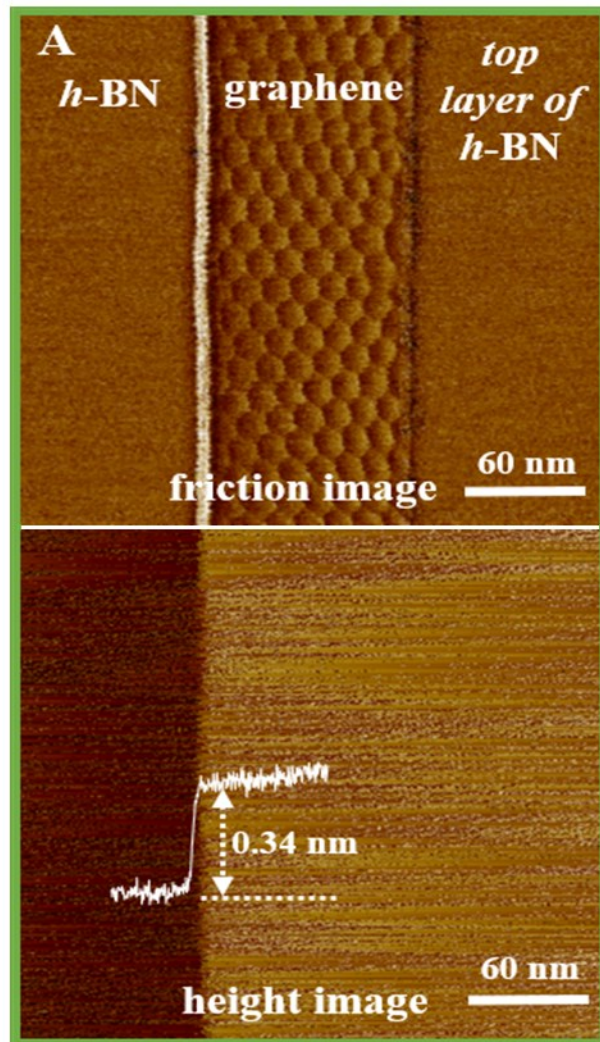


Edge along Armchair(AC)



Edge along Zigzag (ZZ)

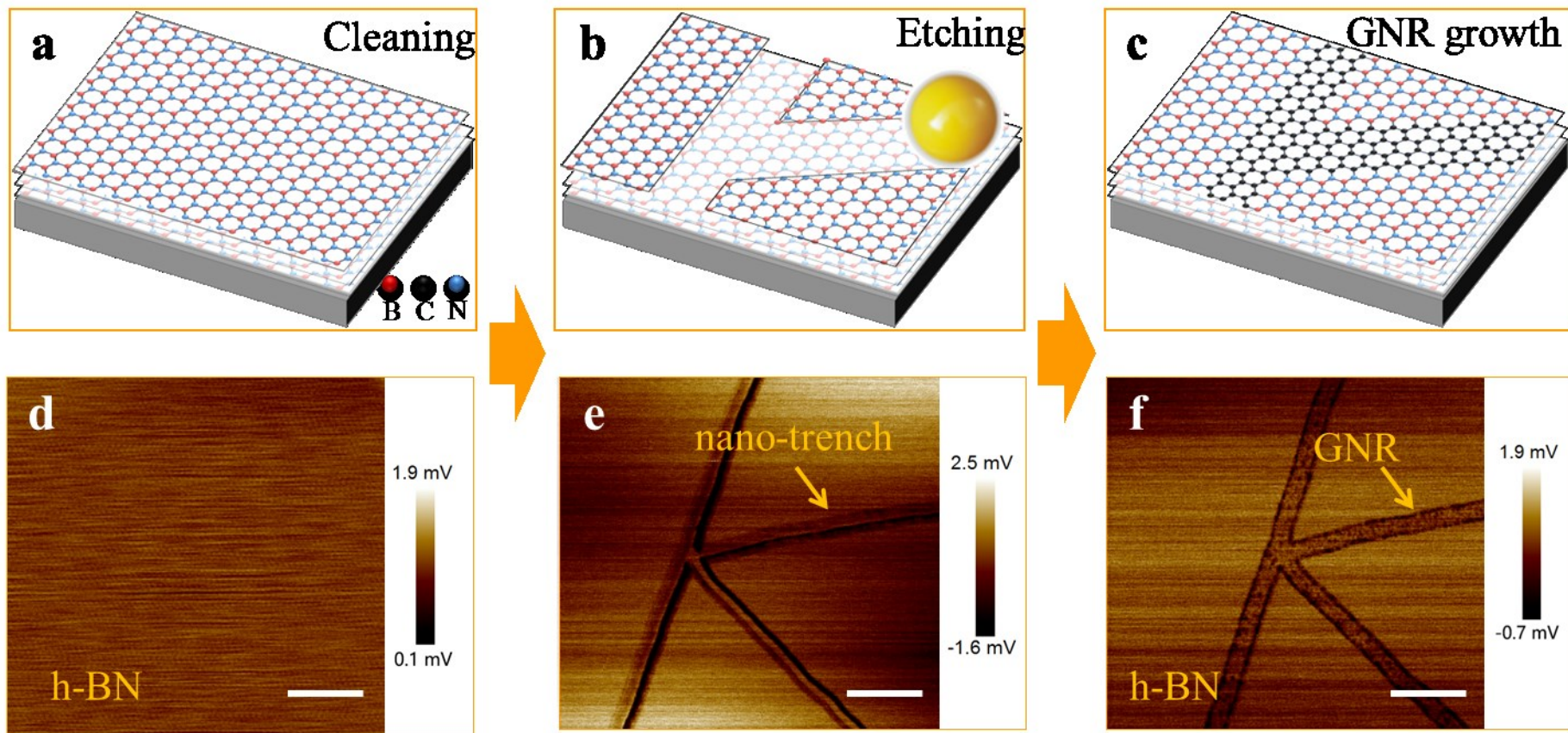
Epitaxial Graphene Ribbons Grown from hBN Step-edges



Outline

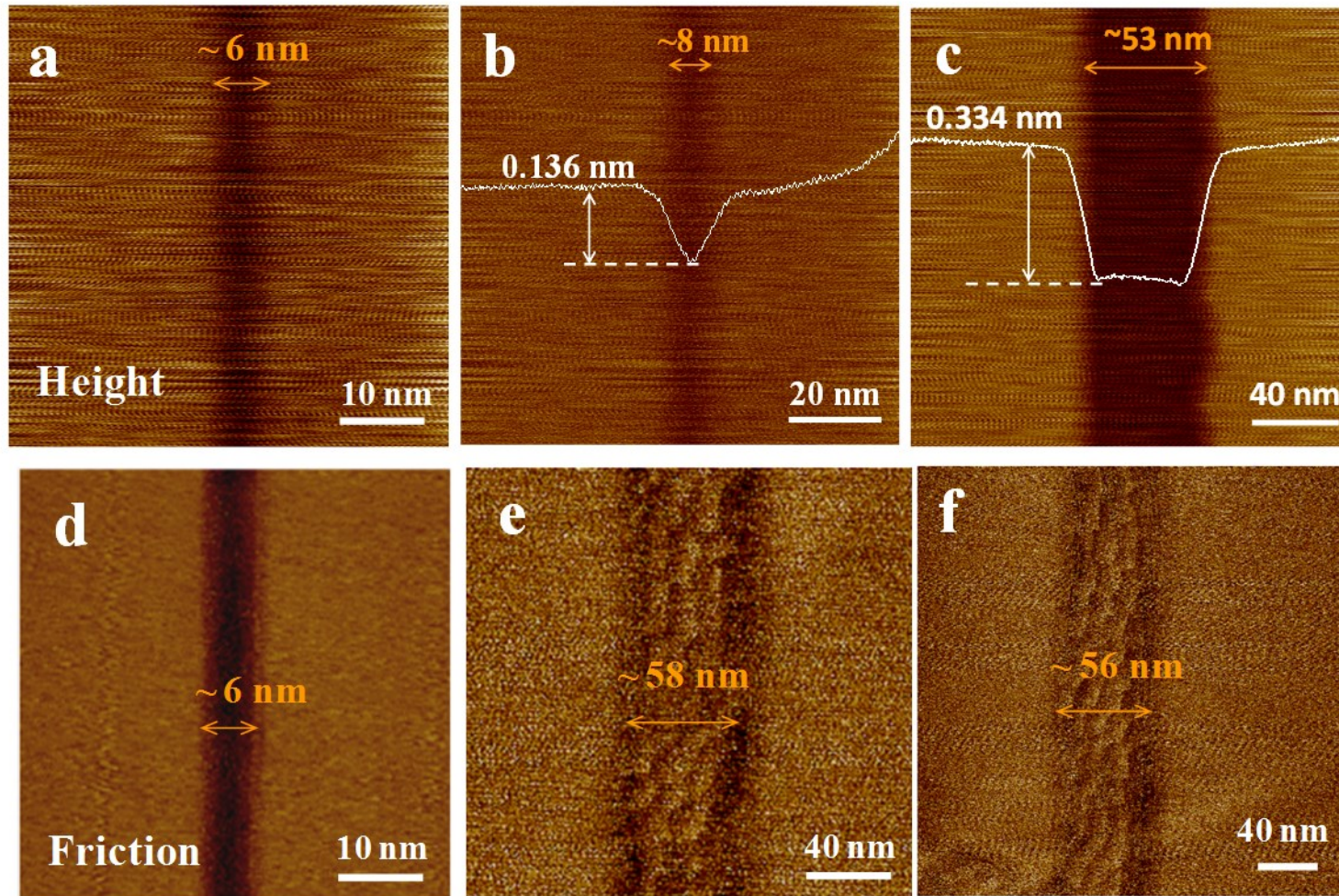
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Synthesis concept for GNRs on hBN



Chen L. Wang H. *et al* Nature Communs.8,14703 (2017)

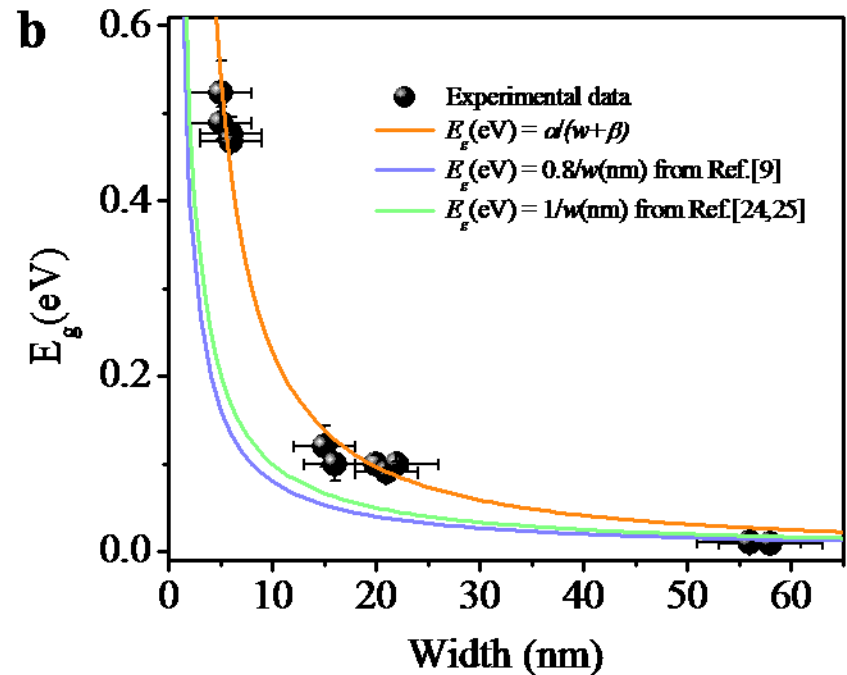
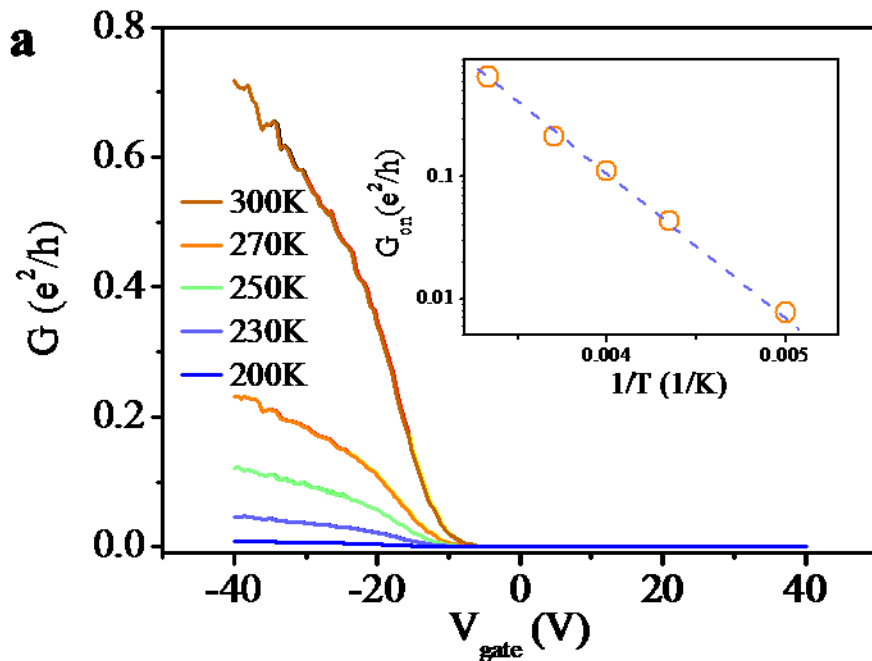
Characterization of Trenches and GNRs



Chen L. Wang H. *et al* Nature Communs.8,14703 (2017)

PCT/CN2011/078070; 特願2015-206777; P2015-206777, US 13/580,240

Band Gap Engineering of GNRs



□ Sub-5nmGNR-FET On/Off ratio beyond 10^4 ;

□ Mobility is more than $700 \text{ cm}^2/\text{Vs}$;

□ Transport gap more than 0.4eV

Chen L. Wang H. *et al* Nature Commun.8,14703 (2017)

Summary

- ◆ **Nucleation at imperfections**
- ◆ **Gaseous catalyst assistance**
- ◆ **Alignment determination**
- ◆ **Nano-trench templates**
- ◆ **GNRs from spatial confinement**

Acknowledgements

Experiments @ SIMIT: *Lingxiu Chen, Li He, Huishan Wang, Shujie Tang, Hong Xie, Tianru Wu, Xiaoming Xie and Mianheng Jiang*

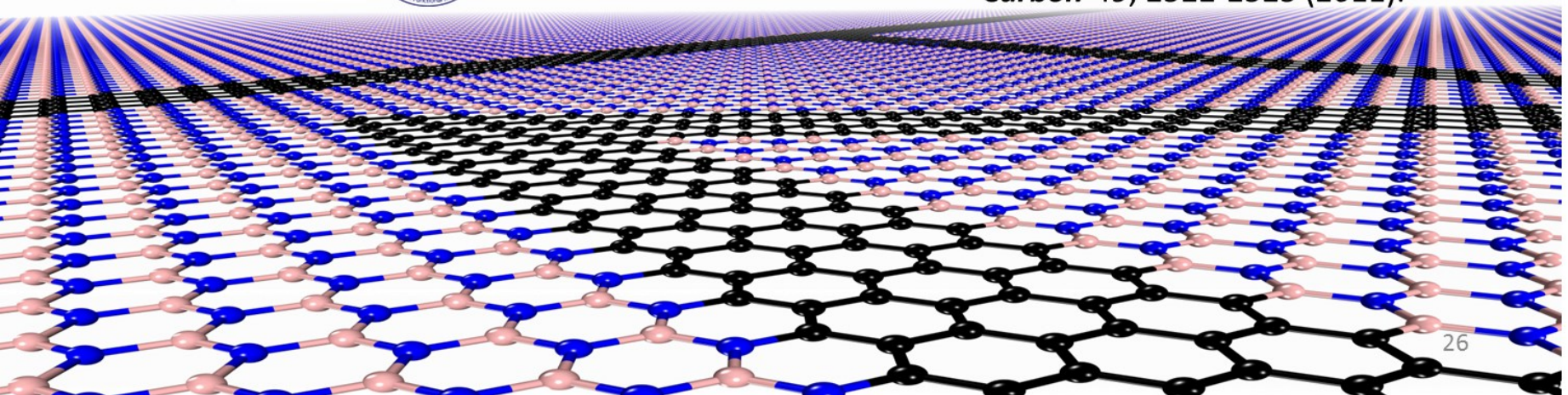
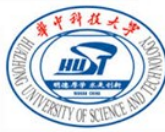
Modeling @ IBS: *Feng Ding, Qinghong Yuan*

Raman @ NTU& Fudan: *Ting Yu , CX Cong*

hBN Crystals @ NIMS & KSU: *T. Taniguchi, K. Watanabe & J. H. Edgar*



Nature Comm. 8:14703 (2017);
Nanoscale, 10.1039/C7NR02578E(2017);
Nature Comm.6:6499 (2015);
Scientific Reports 3:2666 (2013);
Carbon 50, 329-331 (2012).
Carbon 49, 2522-2525 (2011).



Thank you for your attention!